(19) World Intellectual Property Organization

International Bureau



(43) International Publication Date 7 October 2004 (07.10.2004)

PCT

(10) International Publication Number WO 2004/086460 A 2

(51) International Patent Classification⁷:

H01L

(21) International Application Number:

PCT/US2004/008724

(22) International Filing Date: 22 March 2004 (22.03.2004)

(25) Filing Language:

English

(26) Publication Language:

English

(30) Priority Data:

60/456,775 60/456,770 21 March 2003 (21.03.2003) US 21 March 2003 (21.03.2003) US

(71) Applicant (for all designated States except US): NORTH CAROLINA STATE UNIVERSITY [US/US]; 2401 Research Drive, Suite 1122, Campus Box 8210, Raleigh, NC 27695-8210 (US).

(72) Inventors; and

- (75) Inventors/Applicants (for US only): JOHNSON, Mark, Allan, Lamonte [US/US]; 1023 West South Street, Raleigh, NC 27603 (US). BARLAGE, Douglas, William [US/US]; 2809 Montcastle Court, Durham, NC 27705 (US).
- (74) Agent: HUNT, Gregory, A.; Jenkins, Wilson & Taylor, P.A., Suite 1400, University Tower, 3100 Tower Boulevard, Durham, NC 27707 (US).

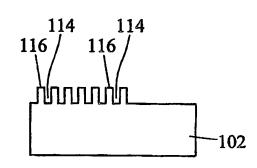
- (81) Designated States (unless otherwise indicated, for every kind of national protection available): AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BW, BY, BZ, CA, CH, CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, EG, ES, FI, GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NA, NI, NO, NZ, OM, PG, PH, PL, PT, RO, RU, SC, SD, SE, SG, SK, SL, SY, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, YU, ZA, ZM, ZW.
- (84) Designated States (unless otherwise indicated, for every kind of regional protection available): ARIPO (BW, GH, GM, KE, LS, MW, MZ, SD, SL, SZ, TZ, UG, ZM, ZW), Eurasian (AM, AZ, BY, KG, KZ, MD, RU, TJ, TM), European (AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HU, IE, IT, LU, MC, NL, PL, PT, RO, SE, SI, SK, TR), OAPI (BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG).

Published:

 without international search report and to be republished upon receipt of that report

For two-letter codes and other abbreviations, refer to the "Guidance Notes on Codes and Abbreviations" appearing at the beginning of each regular issue of the PCT Gazette.

(54) Title: METHOD AND SYSTEMS FOR SINGLE- OR MULTI-PERIOD EDGE DEFINITION LITHOGRAPHY



(57) Abstract: Methods and systems for multiperiod, edge definition lithography are disclosed. According to one method, a first material is isotropically deposited on a substrate and on a field mesa also located on the substrate. The first masking material is then anisotropically removed from the substrate to leave a nanometer-pitched sidewall adjacent to the field mesa. A second masking material is then isotropically deposited on the substrate, the sidewall, and the field mesa. The second masking material is then anisotropically removed from the substrate to leave a second nanometer-pitched sidewall adjacent to the first sidewall. The process may be repeated to create alternating nanometer-pitched sidewalls of the first and second masking materials. One of the first and second masking materials may then be etched from the substrate to leave

nanometer-pitched channels in one of the masking materials. The channels may be used to etch nanometer-pitched features in the substrate.